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Experimental and theoretical studies on corrosion inhibition of 4-amidinophenyl-2,2'-bifuran and its analogues in acidic media†

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Corrosion inhibition studies of carbon steel (CS) in 1 M HCl by newly synthesized bichalcophene compounds namely; 4-(2,2'-bifuran-5-yl)benzamidine (MA-0947) and 6-(2,2'-bifuran-5-yl)nicotinamide (MA-0941) and 6-[5-(thiophen-2-yl)furan-2-yl]nicotinamide (MA-0940) have been conducted using chemical and electrochemical methods. MA-0940 exhibited the highest inhibition efficiency % $\eta = 95\%$ at 18×10^{-6} M. The adsorption and thermodynamic activation parameters were calculated and discussed. Potentiodynamic polarization (PP) studies showed that the investigated compounds act as mixed-type inhibitors and chemically adsorbed on CS surface following the Langmuir adsorption isotherm. The surface morphology was analyzed using Atomic Force Microscopy (AFM). The effect of molecular structure on the inhibition efficiency has been explored by quantum chemical computations. The relation between the inhibition efficiency and some quantum parameters has been discussed and obvious correlations were observed. The binding energies of tested bichalcophene derivatives on Fe (110) surfaces were calculated using molecular dynamics simulation. The adsorption energies between metal surface and investigated bichalcophenes followed the order: MA-0940 > MA-0941 > MA-0947 and this order is in good agreement with the experimental data.

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1. Introduction

CS has significant industrial and economic importance owing to its unique mechanical properties and low cost compared to other metal alloys. Corrosion has always been a fundamental research subject and an industrial concern that gains endless attention.^{1,2} Corrosion of iron and its alloys causes huge financial loss, especially in petrochemical and oil-gas industries where acid solutions are commonly utilized in various operations, *e.g.*, descaling, cleaning, pickling and oil-well acidizing applications.³ There is, however, a major risk to use acid solutions without further treatment with corrosion inhibitors because CS is severely attacked by acid solutions. Therefore, the use of corrosion inhibitors is a fundamental method to corrosion of metals in acidic media.^{4,5} The majority of efficient corrosion inhibitors are generally organic compounds that contain one or more heteroatoms, P, S, N, and O, which act as active centers because of their high electron density and great tendency to donate electrons that facilitate the adsorption process on metal surface and interfere with corrosion reactions occurring on metal surface, thereby protecting the metal and

increasing the lifetime. The efficiency of an organic inhibitor in corrosion system depend on how strong the inhibitor is adsorbed on metal surface and its adsorption is directly linked to some physiochemical properties, structural electronic features, the nature of testing electrolyte and the charge on metal surface.^{6,7} It is well recognized that sulfur and nitrogen containing compounds have showed greater inhibition than those having only one of these atoms. Recently, much research on developing new efficient, eco-friendly and safe corrosion inhibitors has become very popular. To the authors' best knowledge, bichalcophene compounds have been scarcely evaluated as corrosion inhibitors. In a recent study we evaluated the corrosion inhibition characteristics of two bichalcophene compounds namely; 4-amidinophenyl-2,2'-bithiophene and its aza-analogue in which the results indicate that these compounds are excellent corrosion inhibitors and suggest their study would be meriting.⁸ In addition to this, taking into account the actual ecological problems, the interest for these compounds is also emphasized due to their non-toxic characteristics coupled with high solubility in the test solution, which enhances their inhibition efficiency. In view of this, our aim is to shed more light on the corrosion inhibitive properties of bichalcophene derivatives. In the present work, we have studied the corrosion inhibition of some other cationic bichalcophenes namely; 4-(2,2'-bifuran-5-yl)benzamidine (MA-0947), 6-(2,2'-bifuran-5-yl)nicotinamide (MA-0941), and 6-[5-(thiophen-2-yl)furan-2-yl]nicotinamide (MA-0940) on the corrosion

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behaviour of CS in 1 M HCl using different experimental and theoretical techniques. The tested bichalcophenes in this manuscript have been recently reported for their significant DNA-binding affinity,⁹ antibacterial,¹⁰ antimutagenic,¹¹ and antiproliferative activities.¹² In addition, bifuran derivative MA-0947 was proven to be more effective than vancomycin against methicillin-resistant *Staphylococcus aureus* infection in mice.¹³ Surface examination was conducted by atomic force microscopy (AFM). Quantum chemical computations and molecular dynamics simulation were analyzed and discussed. The study also aimed to portray the influence of molecular structure on the capability of these molecules to be adsorbed on the metal surface.

2. Experimental section

2.1. Materials and reagents

Seven identical CS specimens were cut out from CS sheet with chemical composition (wt%): C (0.076), Mn (0.19), P (0.012), Si (0.026), Cr (0.05), Al (0.023), and Fe (balance). The surface of CS samples and the working electrode was polished to mirror finish using different grades (400–2000) from grit emery papers, washed with deionized water, degreased in acetone. The test solution (1 M HCl) is diluted from HCl (37%) using ultrapure double distilled water.

2.2. Inhibitors

The molecular structures of investigated compounds are given in Table 1 and the synthetic route is shown in Fig. 1. The full details on the preparation methodology and structural elucidation of cationic bichalcophene **2a–c**, including spectral data (IR, NMR, and Mass) has been earlier reported,⁹ and the same batch is used herein in our study. Preparation and characterization of starting material **1a** & **1b** is previously reported.^{14,15} The doses of inhibitor were 3×10^{-6} , 6×10^{-6} , 9×10^{-6} , 12×10^{-6} , 15×10^{-6} , and 18×10^{-6} M.

2.3. Atomic absorption measurements

Atomic Absorption Spectroscopy (AAS) is utilized to determine the amount of iron dissolved in uninhibited and inhibited 1 M HCl solutions after CS specimens are kept immersed in test solutions for 12 h. The inhibited dose of investigated compounds was 18×10^{-6} M. The % η_a was determined according to the following equation:

$$\% \eta_a = \frac{(U - I)}{U} \times 100 \quad (1)$$

where % η_a refers to the percentage of inhibition, and U , I are the amount of dissolved iron determined in free and inhibited 1 M HCl solutions, respectively.

2.4. Mass loss (ML) method

ML is a convenient and common method to evaluate the performance of corrosion inhibitors in acid solutions. The initial weight of thoroughly polished CS samples was pre-determined before immersion into 100 ml of 1 M HCl solution

without and with different doses of MA-0940, MA-0941 and MA-0947. The total immersion time was 3 h and the experiments were conducted at different temperatures. Every 30 minutes CS samples were removed from the solution, washed with double distilled water, then gently dried with air and the weight is determined again. ML measurements were conducted in triplicate and the average ML was calculated for reproducibility. The mass of each CS sample was measured before and after immersion using digital analytical balance with accuracy 0.0001 g.

2.5. Electrochemical methods

Electrochemical measurements employing ac and dc techniques were conducted using conventional three-electrode cell assembled in glass compartment with CS as working electrode (WE), a platinum foil as an auxiliary electrode, and a saturated calomel electrode (SCE) as reference electrode. The reported potentials in this work were measured with reference to the SCE. A framework from Gamry was used for all measurements. The procedure started with allowing the WE to reach a steady state by immersion into a test solution for 1 h at open circuit potential (E_{OCP}). Then electrochemical impedance spectroscopy (EIS) was performed on the CS electrode at the E_{OCP} . A perturbation signal with amplitude 10 mV was applied in the frequency range from 100 kHz to 0.02 Hz. The EIS data were fitted and analyzed carefully by E-chem analyst software. EFM measurements were utilized with 10 mV potential disturbance signal with two frequencies 2 and 5 Hz and the base frequency was 0.1 Hz with 12 cycles. At last, Tafel polarization curves were obtained by sweeping the electrode potential in the range of ± 700 mV versus the E_{OCP} with a scan rate of 1 mV s^{-1} . The same test was conducted 3 times to ensure a satisfactory reproducibility.

2.6. Morphology analysis

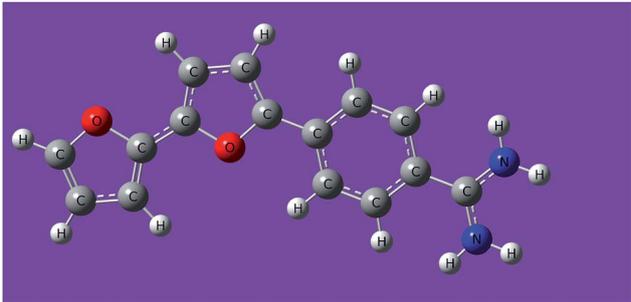
Atomic force microscopy AFM (Nanosurf Flex) was used to examine the polished surface of CS samples before and after 12 h immersion in 1 M HCl blank solution, and inhibited solution with 18×10^{-6} M of inhibitors at 298 K.

2.7. Computational details

2.7.1. Dmol³. Quantum chemical parameters along with Fukui function indices were computed using DMol³ code installed in Materials Studio software version 7.0.¹⁶ All electronic calculations were accomplished using GGA/BLYP method with a double numerical basis set (DNP) with d and p polarization. The effect of solvent (aqueous phase) was considered in DMol³ calculations by including COSMO controls.¹⁷ The reliability of DNP basis set of Dmol³ method were compared with the computations obtained from Gaussian 09 program package at density functional theory (DFT) level using the 6-31G (d,p) basis set for all atoms and the atomic charges were determined using natural bond orbital (NBO) analysis.¹⁸ The preferential adsorption centers of the inhibitor molecule could be predicted from the plots of Frontier Molecular Orbitals (FMOs). The quantum parameters chemical softness (σ), hardness (η),



Table 1 Chemical names, molecular structures, molecular formulas of the studied bichalcophenes

Inhibitor code	Molecular structures/chemical name	Mol formulas (F. wt)
MA-0947	 Chemical name: 4-(2,2'-bifurane-5-yl)benzamidine	C ₁₅ H ₁₂ N ₂ O ₂ -1HCl (288.72)
MA-0941	 Chemical name: 6-(2,2'-bifuran-5-yl)nicotinamidine	C ₁₄ H ₁₁ N ₃ O ₂ -1HCl-0.8H ₂ O (336.26)
MA-0940	 Chemical name: 6-[5-(thiophen-2-yl)furan-2-yl]nicotinamidine	C ₁₄ H ₁₁ N ₃ OS-2HCl (342.24)

electronegativity (χ), chemical potential (Π), and electrophilicity index (ω) were calculated. These parameters are related to each other as follows;¹⁹⁻²¹

$$\eta = 1/2(E_{\text{LUMO}} - E_{\text{HOMO}}) \quad (2)$$

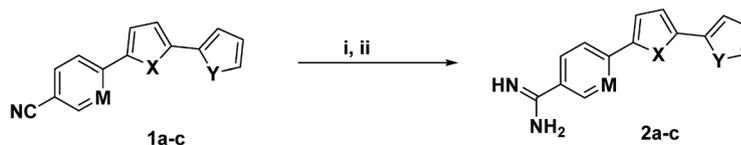
$$\sigma = 1/\eta \quad (3)$$

$$\chi = 1/2(E_{\text{HOMO}} + E_{\text{LUMO}}) \quad (4)$$

$$\Pi = -\chi \quad (5)$$

$$\omega = (\Pi)^2/2\eta \quad (6)$$

2.7.2. Molecular dynamic (MD) modelling. The simulation of adsorption for one single molecule of investigated inhibitors on CS surface was performed with MD method using COMPASS,



2a (MA-0947); M = CH, X=Y = O
 2b (MA-0941); M = N, X=Y = O
 2c (MA-0940); M = N, X = O, Y = S

Fig. 1 Synthetic route of 4-amidinophenyl-2,2'-bifuran (2a) and its nicotinamidine isosteres 2b & 2c. Reagents and conditions: (i) lithium bis(trimethylsilyl) amide, (ii) ethanol/hydrogen chloride.



an *ab initio* Force-Field Optimized for Condensed-Phase, from Accelrys Inc.^{22,23} Since Fe (110) cleavage surface has the most stable low Miller index, it has been adopted to represent CS substrate. The interaction between bichalcophene derivatives and CS (110) surface was simulated in a box (2.2 × 2.2 × 4.3 nm) using a Monte Carlo search implemented in Material studio software package. The spatial position of iron atoms in Fe (110) were kept fixed, and the surface plane was loaded with one protonated molecule of inhibitor, 4H₃O⁺, 5Cl⁻ and 200 water molecules to model part of the studied corrosion system at the atomistic level. The course of interaction was processed until a low energy adsorption configuration is established. The procedure used to prepare the iron surface and build the modelling corrosion system is described in more details elsewhere.²⁴ The top layer was defined as the adsorption surface region and selected as target atoms. The maximum distance between the adsorbate molecule and the surface target atoms was 15 Å. All structures included in this method are geometrically optimized to ensure the accuracy of the results. Although this is an oversimplification for the factual system, it is sufficiently elucidate the variations in the adsorption action of investigated molecules and provide adequate proof to rationalize our experimental results.

3. Results and discussion

3.1. Atomic absorbance spectroscopy (AAS)

The quantitative analysis from AAS measurements are given in Table 2, it is clear from the results that the amount of dissolved iron was significantly lower in inhibitor-containing solution than in free acid solution. MA-0940 and MA-0941 are more efficient inhibitors and the values of % η followed this order MA-0940 < MA-0941 < MA-0947.

3.2. Mass loss (ML) method

3.2.1. Effect of dose. The relationship between ML corrosion parameters and the dose of MA-0940 is displayed in Fig. 2 and similar results obtained for MA-0947 and MA-0941 are presented in Fig. S1 in the ESI.† The ML corrosion parameters of tested compounds in Table 3 such as corrosion rate (CR) and η_{ML} are determined using the following equations;

$$CR = \frac{W_i - W_f}{At} \quad (7)$$

$$\% \eta_{ML} = \left(\frac{CR^* - CR}{CR^*} \right) \times 100 \quad (8)$$

Table 2 The content of iron dissolved in 1 M HCl blank and inhibited solutions containing (18 × 10⁻⁶ M) of the investigated compounds

Inhibitor	Amount of iron content (μg mL ⁻¹)	% η_a
Free/blank	7.157	
MA-0947	0.563	92.13
MA-0941	0.402	94.38
MA-0940	0.334	95.33

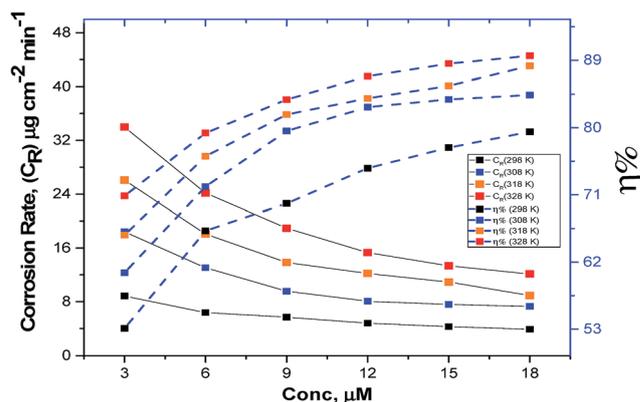


Fig. 2 Variation of CR and % η with difference doses of MA-0940.

It is noted that the existence of bichalcophene derivatives in test solution caused a decrease in (CR), reflecting an increase in % η_{ML} . This influence is extended at all studied doses of investigated bichalcophenes. The maximum inhibitory potential was observed when the test solution was pretreated with (18 × 10⁻⁶ M) of the investigated compounds. This finding might be due to the abundance of electron donors (S and N) and aromatic rings at metal/solution interface with incremental dose of inhibitors. In acidic solutions, during the anodic reaction of corrosion process, Fe²⁺ dissolves into aqueous solution, simultaneously the cathodic reaction resulting in discharging H⁺ adsorbed at metal surface to produce H₂ or reduction of O₂. However, in inhibitor-containing solutions, the anodic or/and cathodic reactions retarded by the adsorption of inhibitor molecules on the metal surface. From the results in Table 3, MA-0940 exhibited the highest inhibition efficiency, while MA-0947 showed the lowest inhibition efficiency in this study. The variation in the % η_{ML} could be due to the difference in molecular structure features. The unshared e⁻ on N, S and O atoms contribute in the adsorption of these molecules on CS surface (chemisorption) and enhances the inhibitory potential of compounds compared to phenyl bifuran compound MA-0947. Aromatic rings are responsible for the weak electrostatic interaction between inhibitors and CS surface (physisorption).²⁵ Furthermore, bichalcophene species are easily protonated in acid media which also take part in the competing adsorption with Cl_{ads}⁻ ions adsorbed on CS surface.

3.2.2. Influence of temperature. The influence of temperature on the corrosion behaviour of CS in uninhibited and inhibited test solution was examined. The adsorption mechanism (physically or chemically onto metal surface) can be proposed from the analysis of these information. Chemical adsorption is strengthened by increasing the temperature, while at lower temperature physisorption predominates. The apparent activation energy (E_a^*) is related to corrosion rate CR as described by Arrhenius equation:²⁶

$$\log CR = \frac{-E_a}{2.303RT} + \log A \quad (9)$$

where, T is absolute temperature, R is universal gas constant (8.314 J K⁻¹ mol⁻¹), and A is the Arrhenius pre-exponential



Table 3 ML corrosion parameters of CS in 1 M HCl in nonexistence and existence of various doses of bichalcophene derivatives at different temperatures

$[C_{inh}]$ (M)	25 °C		35 °C		45 °C		55 °C	
	CR (mg cm ⁻² min ⁻¹) × 10 ⁻³	% η	CR (mg cm ⁻² min ⁻¹) × 10 ⁻³	% η	CR (mg cm ⁻² min ⁻¹) × 10 ⁻³	% η	CR (mg cm ⁻² min ⁻¹) × 10 ⁻³	% η
0	18.83	—	46.73	—	75.87	—	116.66	—
MA-0947								
3 × 10 ⁻⁶	10.38	44.89	22.49	51.87	33.55	55.79	46.06	60.52
6 × 10 ⁻⁶	7.88	58.17	16.80	64.05	23.92	68.47	31.82	72.73
9 × 10 ⁻⁶	6.92	63.23	13.10	71.97	18.67	75.39	26.27	77.48
12 × 10 ⁻⁶	6.09	67.64	11.55	75.28	15.75	79.24	23.08	80.22
15 × 10 ⁻⁶	5.27	72.02	10.08	78.42	14.00	81.55	19.64	83.16
18 × 10 ⁻⁶	4.69	75.08	9.16	80.39	12.08	84.07	17.23	85.23
MA-0941								
3 × 10 ⁻⁶	9.32	50.52	19.89	57.42	28.03	63.05	37.88	67.53
6 × 10 ⁻⁶	6.99	62.91	13.88	70.31	18.91	75.07	26.6	77.2
9 × 10 ⁻⁶	6.04	67.95	10.54	77.45	15.36	79.75	21.72	81.39
12 × 10 ⁻⁶	5.21	72.33	9.17	80.38	12.81	83.12	18.63	84.03
15 × 10 ⁻⁶	4.52	76.02	8.17	82.5	11.59	84.73	15	87.14
18 × 10 ⁻⁶	4.07	78.41	7.79	83.33	9.77	87.13	13.39	88.52
MA-0940								
3 × 10 ⁻⁶	8.83	53.10	18.42	60.58	26.08	65.62	33.99	70.86
6 × 10 ⁻⁶	6.37	66.19	13.04	72.09	18.08	76.17	24.16	79.29
9 × 10 ⁻⁶	5.68	69.85	9.56	79.55	13.84	81.76	18.94	83.76
12 × 10 ⁻⁶	4.79	74.56	8.06	82.75	12.20	83.92	15.32	86.87
15 × 10 ⁻⁶	4.27	77.32	7.57	83.79	10.92	85.61	13.35	88.56
18 × 10 ⁻⁶	3.87	79.45	7.30	84.38	8.90	88.27	12.11	89.62

factor. Furthermore, other thermodynamic activation parameters were calculated using transition state equation:²⁷

$$\log k_{\text{corr}} = \log(R/Nh) + (\Delta S^*/2.303R) + \Delta H^*/2.303RT \quad (10)$$

where, N is Avogadro's number, h is Planck's constant, ΔH^* and ΔS^* is the enthalpy and entropy of activation, respectively. Fig. 3 gives an example of Arrhenius and transition state plots for dissolution of CS in 1 M HCl without and with different doses of

MA-0940. Similar plot for MA-0947 and MA-0941 are given in Fig. S2 in the ESI.†

The values of E_a were determined from the slopes of straight lines in Fig. 3a. The values of ΔH^* and ΔS^* were also evaluated from the straight lines Fig. 3b. The slope of these lines $[-\Delta H^*/(2.303R)]$ and intercept $[\log(R/Nh) + \Delta S^*/(2.303R)]$, respectively. The values of E_a , ΔH^* and ΔS^* are listed in Table 4.

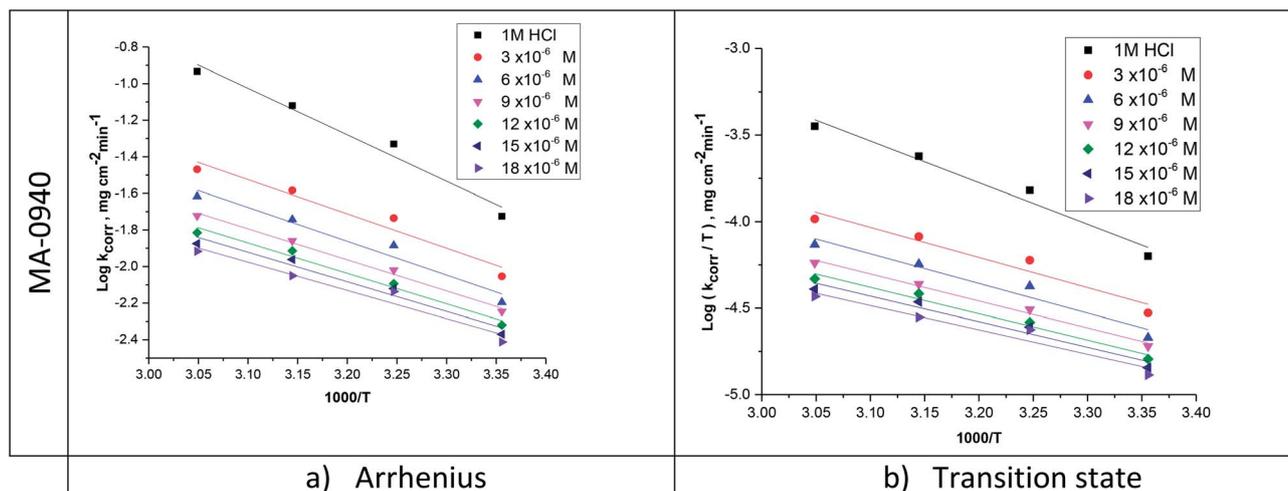


Fig. 3 (a) Arrhenius and (b) transition state plots for CS corrosion in 1 M HCl in the absence and presence of MA-0940.



Table 4 Activation thermodynamic parameters for dissolution of CS with and without 18×10^{-6} M of investigated bichalcophene derivatives and ΔG^* at different temperatures

Inh	Activation parameters			$+\Delta G^*$			
	E_a (kJ mol ⁻¹)	ΔH^* (kJ mol ⁻¹)	ΔS^* (J mol ⁻¹ K ⁻¹)	298 K	308 K	318 K	328 K
1 M HCl	48.60	46	-122.49	36.55	37.77	39	40.22
MA-0947	34.09	31.49	-183	54.56	56.39	58.22	60.05
MA-0941	31.04	28.45	-194.33	57.94	59.88	61.83	63.77
MA-0940	29.57	26.97	-199.70	59.54	61.53	63.53	65.53

Generally, chemisorption mechanism is indicated from the higher value of E_a observed for free acid solution compared to the inhibited one. This can be explained in terms of a shift of net corrosion process from exposed surface to adsorbed sites accounts for decrease in E_a at higher levels of inhibition.²⁸ Also, increase in E_a at higher temperatures can be associated with decrease in adsorption of inhibitor molecules onto metal surface. The results in Table 4 showed that the values of E_a in the presence of bichalcophene compounds are lower than that of the blank solution. This supports chemisorption mechanism in which a co-ordination bond is formed due to sharing and/or transition of electrons from inhibitors to vacant-d-orbital of iron surface atoms, interfering with the anodic reaction of the corrosion process.²⁹ However, a lower value of E_a in the presence of Cl^- compared to free solution suggests chemisorption of inhibitor molecules. The values of E_a and ΔH^* in Table 4 are relatively close and follow the same pattern. This is in line with the concept of transition-state theory. A positive value of ΔH^* indicates that the metal dissolution is an endothermic process.³⁰ This has also been reported to be indicative of retarded dissolution of metal in inhibitor-containing solution.

The values of ΔS^* for three inhibitor molecules are negative, indicating that the rate determining step involves association rather than dissociating phenomenon in the formation of activated complex.³¹ This means, transition from reactants to activated complex was accompanied by decrease in disorder. In the presence of inhibitors, the discharge of hydrogen ions to form adsorbed hydrogen atoms at the metal surface will be prevented by the adsorption of inhibitor molecules. This causes the system to pass from a more orderly to a less orderly arrangement. It was also observed that the ΔS^* in the presence of MA-0940 is more negative than that of other inhibitors. This may be attributed to the larger molecular weight of MA-0940, resulting in a more pronounced decrease in disorderliness upon activated complex formation. The change in free energy (ΔG^*) activation for CS in 1 M HCl in the absence and presence of investigated compounds was calculated using the equation:

$$\Delta G^* = \Delta H^* - T\Delta S^* \quad (11)$$

The values of ΔG^* listed in Table 4 are positive suggesting that the activated complex is unstable. ΔG^* increases very slightly with increasing temperature, suggesting that relative thermodynamic favorability of activated complex formation decreases with increasing temperature.

3.2.3. Adsorption isotherms. The inhibition action of corrosion inhibitor is dependent on its adsorption behaviour on CS surface. Since the interaction forces between water molecules and CS surface is lower than the one between the inhibitor compound and CS surface, a substitution adsorption process can be established and water molecules adsorbed on the metal surface (H_2O)_{ads} are replaced by inhibitor molecules in the aqueous phase (Org_{aq}).



where x represents the size ratio; the number of water molecules substituted with one inhibitor molecule. The adsorption of inhibitors can either occur physically or chemically on a corroding CS surface, where the physisorbed molecules retard metal dissolution by inhibiting the cathodic reaction while chemisorbed molecules inhibit the anodic reaction by reducing the inherent reactivity of the metal at adsorption sites. Langmuir adsorption isotherm showed the best fit for all tested bichalcophenes which is defined by the following equation:³²

$$C/\theta = \frac{1}{K_{ads}} + C \quad (13)$$

where K_{ads} is the equilibrium constant of adsorption process and C is dose of inhibitor. Linear plots of C/θ versus C for investigated compounds are obtained. Only Langmuir plots for MA-0940 are presented in Fig. 4. Langmuir linear curves for MA-

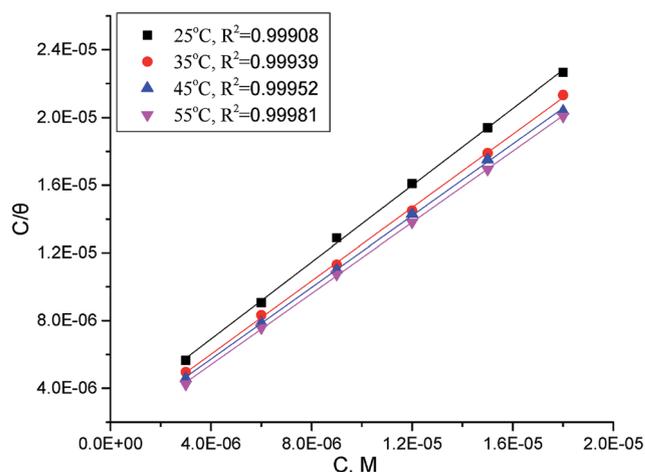


Fig. 4 Langmuir's isotherm plots for adsorption of MA-0940 on CS surface in 1 M HCl.



0947 and MA-0941 are provided in Fig. S3 in the ESI.† The correlation coefficients (R^2) and slope of these linear plots were found close to unity. $\Delta G_{\text{ads}}^\circ$ is an important thermodynamic parameter which can be calculated from the following equation.³³

$$K_{\text{ads}} = \frac{1}{55.5} \exp\left(\frac{-\Delta G_{\text{ads}}^\circ}{RT}\right) \quad (14)$$

where 55.5 is the molar dose of water in mol^{-1} .

In addition, other important thermodynamic adsorption coefficients such as the enthalpy and the entropy of adsorption ($\Delta H_{\text{ads}}^\circ$ and $\Delta S_{\text{ads}}^\circ$ respectively) were calculated according to Van't Hoff equation:

$$\log K_{\text{ads}} = \frac{(-\Delta H_{\text{ads}}^\circ)}{2.303RT} + \text{constant} \quad (15)$$

Plots of $\log(K_{\text{ads}})$ versus $1/T$ in (Fig. 5) are straight lines with slopes $[-\Delta H_{\text{ads}}^\circ/2.303RT]$ used to calculate ($\Delta H_{\text{ads}}^\circ$). From the calculated data of $\Delta H_{\text{ads}}^\circ$ and $\Delta G_{\text{ads}}^\circ$, the entropy of adsorption $\Delta S_{\text{ads}}^\circ$ can be determined according to the general thermodynamic equation:

$$\Delta G_{\text{ads}}^\circ = \Delta H_{\text{ads}}^\circ - T\Delta S_{\text{ads}}^\circ \quad (16)$$

The thermodynamic adsorption parameters for studied bichalcophene derivatives on CS surface are summarized in Table 5, the values of K_{ads} are large and increase with temperature, and this indicates a strong interaction between bichalcophene derivatives and CS surface which is also strengthened with temperature, proving that the investigated compounds are efficient corrosion inhibitors for CS in hydrochloric acid solutions.

From the results in Table 5, the values of $\Delta G_{\text{ads}}^\circ$ are negative and less than -40 kJ mol^{-1} which indicate that bichalcophenes are chemisorbed spontaneously on CS surface. $\Delta G_{\text{ads}}^\circ$ values become more negative on increasing temperature. This reflects the endothermic nature of the adsorption process, which is further confirmed from the positive values of $\Delta H_{\text{ads}}^\circ$. In addition, the large positive values of $\Delta S_{\text{ads}}^\circ$ is commonly typical with endothermic adsorption process. In general, an endothermic process is mostly attributed to chemisorption and involve

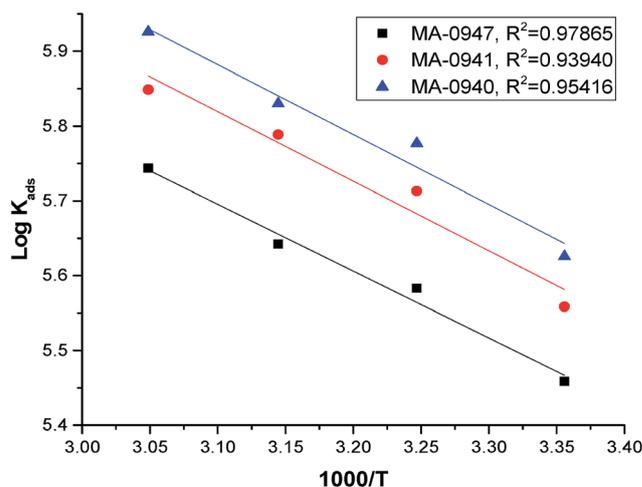


Fig. 5 Curves fitting of ($\log K_{\text{ads}}$ vs. $1/T$) for the adsorption of bichalcophene inhibitors in 1 M HCl.

electron transfer from inhibitor to metal surface to form coordinate bond while exothermic adsorption process suggests either physisorption or chemisorption.³⁴ The unshared electron pairs in investigated molecules may interact with d-orbital of CS to provide chemisorbed film.

3.3. Tafel polarization technique

Tafel plots for CS electrode in uninhibited and inhibitor-containing solutions with different doses of MA-0940 are shown in Fig. 6. Tafel curves of CS in 1 M HCl without and with various doses of Tafel plots for MA-0947 and MA-0941 are given in the ESI (Fig. S4).† The variation of electrochemical parameters, including; corrosion current density (i_{corr}), corrosion potential (E_{corr}), anodic and cathodic Tafel slopes (β_a , β_c), with the dose of inhibitors are summarized in Table 6. The $\eta_{\text{pp}}\%$ are calculated using the following equation:³⁵

$$\eta_{\text{pp}}\% = \frac{i_{\text{corr}}^0 - i_{\text{corr}}}{i_{\text{corr}}^0} \times 100 \quad (17)$$

where i_{corr}^0 and i_{corr} represent the current densities of CS electrode in free and inhibitor-containing solution, respectively.

Table 5 Thermodynamic adsorption parameters of bithiophene derivatives on CS in 1 M HCl with optimum doses at different temperatures

Inhibitor	Temp., K	$K_{\text{ads}}, \times 10^4 \text{ M}^{-1}$	$-\Delta G_{\text{ads}}^\circ, \text{ kJ mol}^{-1}$	$\Delta H_{\text{ads}}^\circ, \text{ kJ mol}^{-1}$	$\Delta S_{\text{ads}}^\circ, \text{ J mol}^{-1} \text{ K}^{-1}$
MA-0947	298	28.75	41.10	16.74	194.10
	303	38.30	43.21		194.66
	313	43.89	44.98		194.09
	323	55.40	47.03		194.42
MA-0941	298	36.18	41.67	17.42	198.29
	303	51.67	43.98		199.36
	313	61.48	45.87		199.03
	323	70.59	47.69		198.50
MA-0940	298	42.25	42.05	17.50	199.85
	303	59.83	44.35		200.83
	313	67.64	46.12		200.07
	323	84.30	48.17		200.22



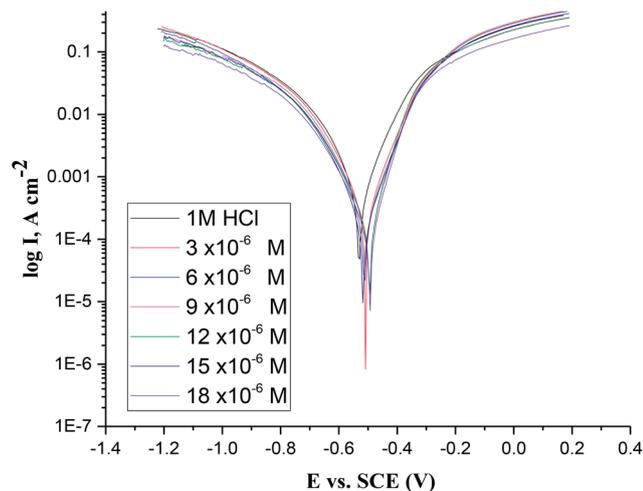


Fig. 6 Tafel curves of CS in 1 M HCl without and with various doses of MA-0940.

Fig. 6 shows a slight shift in both anodic and cathodic lines to lower values of current densities as the dose of investigated compound increases, this reflects a reduction in the corrosion rate of CS in test solutions and the inhibitors are of mixed type at all studied concentration. Also it can be noticed that the corrosion potentials were nearly close to that of the blank solution (1 M HCl), while corrosion current densities of the anodic and cathodic polarization curves has dropped simultaneously.³⁶ This behaviour indicates that bichalcophene

compounds act as mixed-type inhibitors by interfering with both cathodic and anodic reactions occur on CS surface.³⁷

As revealed from results in Table 6, the values of β_a and β_c are similar with the others, showing that the addition of these inhibitors has not changed the nature of corrosion mechanism. The (i_{corr}) decrease and % η increases with increasing the dose of inhibitors. The maximum value of % η_{PDP} is >78% with MA-0940. This accounts for the adsorption of inhibitor molecules on CS surface and blocking the corrosion cells to protect it from corrosion deterioration.

3.4. Electrochemical impedance spectroscopy (EIS) technique

EIS for the dissolution of CS in 1 M HCl without and with various doses of bichalcophene inhibitors were performed to gain more information about the kinetics of the electrode processes. The corresponding EIS (Nyquist and Bode) plots for MA-0940 are given in Fig. 7. Similar EIS diagrams are observed for MA-0947 and MA-0941 and presented in Fig. S5 in the ESI.†

As seen from Fig. 7, Nyquist plots are presented as a single capacitive loop, showing that the dissolution of CS in 1 M HCl without and with inhibition depends on charge-transfer and double layer capacitance at metal/solution interface.³⁸ At all tested doses, the impedance spectra show similar patterns, reflecting that the corrosion mechanism does not change on addition of bichalcophenes inhibitors.³⁹ By contrast, the diameter of semicircles becomes wider with increasing the concentration of investigated bichalcophenes in test solution. It

Table 6 Tafel and EIS parameters of CS in 1 M HCl without and with various doses of investigated inhibitors at 298 K

Conc. (M)	$-E_{\text{corr}}$ (mV per SCE)	i_{corr} ($\mu\text{A cm}^{-2}$)	β_a mV dec $^{-1}$	β_c mV dec $^{-1}$	% η_{PDP}	R_{ct}	C_{dl}	% η_{EIS}
Blank	-530	627.73	101	122	—	32.64	103.36	—
MA-0947								
3×10^{-6}	522	377.67	100	129	39.8	47.80	78.36	31.7
6×10^{-6}	517	365.55	97	116	41.8	57.00	76.16	42.7
9×10^{-6}	515	294.25	85	115	53.1	64.24	65.78	49.2
12×10^{-6}	543	225.57	111	106	64.1	76.13	64.69	57.1
15×10^{-6}	502	190.92	87	126	69.6	83.90	60.53	61.1
18×10^{-6}	517	179.80	89	102	71.4	96.40	59.28	66.1
MA-0941								
3×10^{-6}	513	338.05	89	114	46.1	61.83	54.70	47.2
6×10^{-6}	506	275.34	82	119	56.1	66.33	48.25	50.8
9×10^{-6}	507	202.67	83	124	67.7	73.69	45.32	55.7
12×10^{-6}	518	174.58	102	116	72.2	79.94	42.97	59.2
15×10^{-6}	522	158.43	97	112	74.8	84.01	41.65	61.1
18×10^{-6}	517	140.56	80	101	77.6	91.88	36.77	64.5
MA-0940								
3×10^{-6}	509	294.74	91	112	53.0	73.04	50.79	55.3
6×10^{-6}	512	228.18	92	113	63.6	86.85	46.66	62.4
9×10^{-6}	495	179.29	74	111	71.4	105.30	39.17	69.0
12×10^{-6}	495	173.68	71	114	72.3	125.50	38.26	74.0
15×10^{-6}	518	144.66	78	101	77.0	139.00	40.18	76.5
18×10^{-6}	494	135.55	70	114	78.4	152.90	31.72	78.7



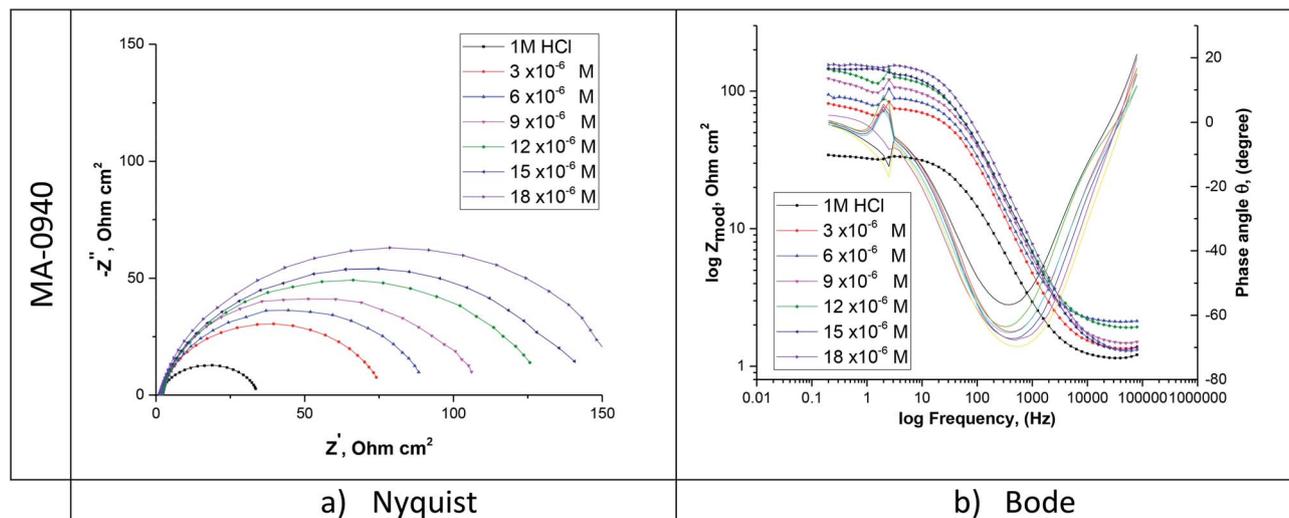


Fig. 7 (a) Nyquist and (b) Bode diagrams for CS in 1 M HCl containing different doses of MA-0940.

is worth mentioning that the centers of Nyquist depressed semicircles were under the real axis due to the dispersion effect in frequency.⁴⁰ This phenomenon appeared because the electrode surface might have roughness, the surface chemical could be heterogeneous especially at grain boundaries, and adsorption-desorption process of the inhibitors molecules at metal/solution interface.⁴¹ Therefore, a constant phase element (CPE) were included in the equivalent circuit in Fig. 8 to analyze the EIS data. Here, R_{ct} is the charge transfer resistance and R_s represents the solution resistance.

EIS data are given Table 6. The CPE impedance (Z_{CPE}) is defined by the following equation,

$$Z_{CPE} = \frac{1}{Y_o(j\omega)^n} \quad (18)$$

where Y_o is the modulus of the CPE, j is the imaginary root ($j^2 = -1$), ω represents the angular frequency, n is the deviation parameter in terms of a phase shift.

When $n = 1$, CPE represents a pure capacitor, for $n = 0$, a pure resistor, and for $n = -1$, an inductor. The values of C_{dl} were calculated as follows,

$$C_{dl} = Y_o(\omega_{max})^{n-1} \quad (19)$$

where $\omega_{max} = 2\pi f_{max}$ and f_{max} is the frequency at the maximum value of the imaginary component of EIS spectra.

The values of η_{EIS} from EIS parameters are calculated by the following equation,

$$\% \eta_{EIS} = \frac{R_{ct} - R_{ct}^*}{R_{ct}} \times 100 \quad (20)$$

where R_{ct} and R_{ct}^* , are the charge transfer resistances for CS in 1 M HCl solution with and without inhibitors, respectively.

It is clear from the results in Table 6 that R_{ct} values increase with increasing the concentration of bichalcophene derivatives in test solution. While, the values of C_{dl} decreased with increasing the concentration of inhibitors.⁴² This behaviour can be attributed to the adsorption of studied bichalcophenes on CS/solution interface which blocks corrosion cells on metal surface and combat corrosion.⁴³ Further, bichalcophene inhibitors gradually substituted water molecules on CS surface which lower the local dielectric constant and increase the thickness of electrical double-layer. All these factors cause C_{dl} to decrease.⁴⁴ Accordingly, corrosion protection was improving with incremental dose of inhibitors, showing that bichalcophene compounds retards corrosion of CS in 1 M HCl solutions. The results of EIS studies were in consistent with ML and PP measurements.

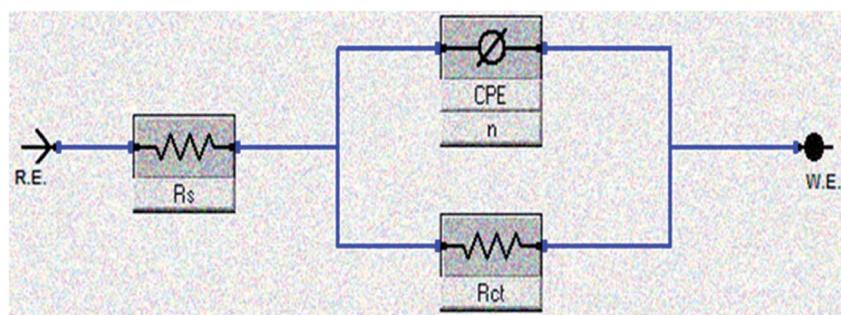


Fig. 8 Equivalent electrical circuit model constructed to fit the EIS data on CS/solution interface.



3.5. Electrochemical frequency modulation (EFM) technique

EFM is a powerful nondestructive electrochemical method used to determine corrosion rate without prior knowledge of the Tafel constants. One main advantage of EFM is that corrosion rate, Tafel parameters and causality factors CF-2, CF-3 are measured in a single data set.⁴⁵ In Table 7 the EFM parameters, for studied corrosion systems, are listed. Fig. 9 shows an example of EFM intermodulation spectra, for CS in uninhibited and inhibited test solution with MA-0940, generated as a result of current response as a function of frequency. Similar EFM spectra for MA-0947 and MA-0941 are displayed in Fig. S6 in the ESI.† The % η_{EFM} was calculated according to eqn (21).

$$\% \eta_{\text{EFM}} = \frac{i_b - i}{i_b} \times 100 \quad (21)$$

where i_b and i are corrosion current densities of CS electrode in blank and inhibitor-containing solutions, respectively.

As can be seen from Table 7, i_{corr} continue to decrease on increasing the inhibitor dose. The causality factors CF-2 and CF-3 are used to check the validity of EFM data and these factors are calculated from the frequency spectrum of the current responses which are found approximately close to the standard values (2 and 3) indicating that the measured data are verified with good quality and not affected by noise.⁴⁶ A minor variation in the actual causality factors from the theoretical values may account for the lower value of the perturbation amplitude or/and the insufficient resolution in the frequency spectrum.⁴⁷

3.6. Atomic force microscopic (AFM) technique

Three dimensional (3D) cross-sectional profiles of AFM images for CS surface are shown in Fig. 10. AFM image in Fig. 10b for

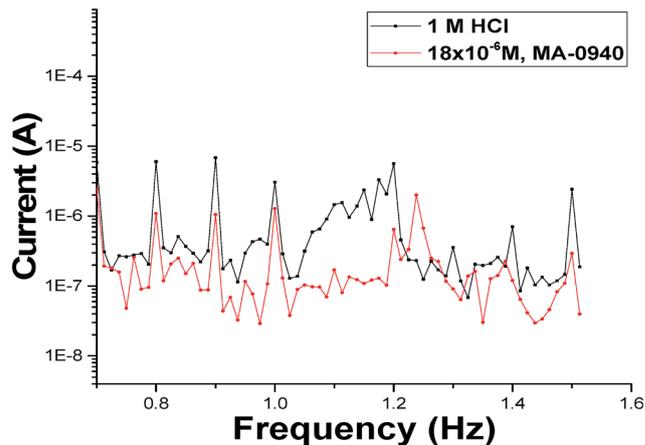


Fig. 9 EFM spectra of (blank) and test solution contains 18×10^{-6} M of MA-0940 at 298 K.

CS surface exposed to blank solution revealed cracked and corroded CS surface due to the acid attack. The surface of CS in the presence of inhibitors was not affected as the one without the inhibitors. The average surface roughness obtained for the polished surface of CS was 46 nm. Estimated average roughness of CS in blank solution was 587 nm, while the corresponding values in the presence of 18×10^{-6} M of MA-0947, MA-0941 and MA-0940 are 123.31 nm, 117.8 nm and 111.2 nm, respectively. These values of surface roughness confirm that the CS surface is protected by the inhibitor molecules, most probably by formation of protective film from inhibitors molecules on CS surface.

Table 7 EFM corrosion parameters for CS in 1 M HCl solutions containing various doses of bichalcophene compounds at 298 K

Conc. (M)	i_{corr} ($\mu\text{A m}^{-2}$)	β_a (mV dec ⁻¹)	β_c (mV dec ⁻¹)	CR mpy	CF-2	CF-3	% η
Blank	549.30	88	93	251	1.08	2.71	—
MA-0947							
3×10^{-6}	306.9	113	135	140.2	2.311	3.026	44.1
6×10^{-6}	298.1	87	98	136.2	1.762	3.226	45.7
9×10^{-6}	270.7	110	130	123.7	1.55	3.068	50.7
12×10^{-6}	247.5	118	133	113.1	2.622	3.703	54.9
15×10^{-6}	241.2	81	97	110.2	2.008	3.053	56.1
18×10^{-6}	221.8	79	95	101.3	1.822	3.49	59.6
MA-0941							
3×10^{-6}	196.3	78	85	89.68	1.163	3.186	64.3
6×10^{-6}	190.3	88	97	86.94	1.618	3.761	65.4
9×10^{-6}	176.1	79	89	80.46	1.575	2.966	67.9
12×10^{-6}	165.7	79	91	75.69	1.703	3.045	69.8
15×10^{-6}	151.6	76	89	69.29	1.86	2.545	72.4
18×10^{-6}	150	78	89	68.55	1.683	3.279	72.7
MA-0940							
3×10^{-6}	127.3	95	104	58.17	1.089	3.528	76.8
6×10^{-6}	114.4	83	90	52.26	1.292	3.622	79.2
9×10^{-6}	108.1	85	92	49.42	1.129	3.287	80.3
12×10^{-6}	95.5	78	93	43.65	1.763	2.721	82.6
15×10^{-6}	93.0	81	90	42.5	2.121	2.434	83.1
18×10^{-6}	89.7	88	110	40.99	1.994	3.415	83.7



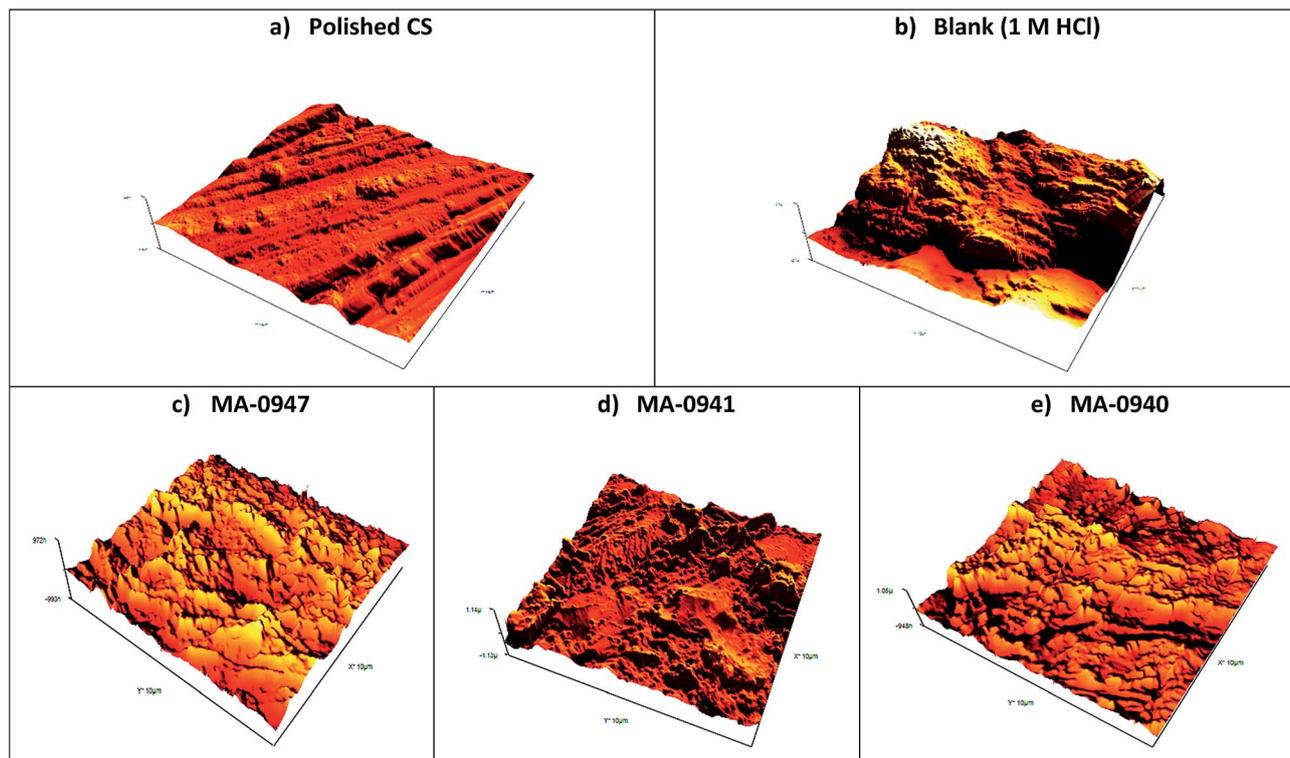


Fig. 10 AFM 3D micrographs for CS surface (a) before, (b) after immersion for 12 h in blank solution and (c) test solution contains 18×10^{-6} M of MA-0947 (d) MA-0941 (e) MA-0940.

3.7. Quantum calculation methods

The use of quantum calculation parameters in corrosion inhibition studies has two main features; first, understanding the

relationship between the molecular structure of inhibitor and its inhibition behavior; secondly, establishing a proposed inhibition mechanism in terms of chemical reactivity of

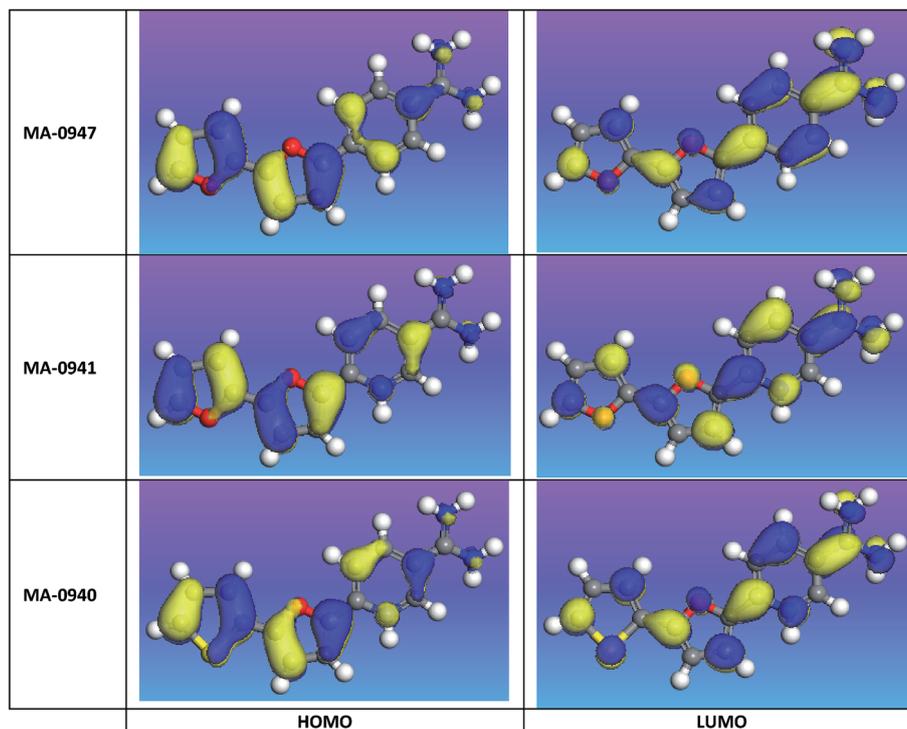


Fig. 11 FMOs of bichalcophene derivatives at DFT-level computational method.



compounds. The molecular reactivity of inhibitors was explored by relating some quantum descriptor variables to the calculated experimental % η values. FMOs of bichalcophene molecules are shown in Fig. 11. It is well acknowledged that the interaction between reacting species occurs *via* the involvement of FMOs *i.e.* HOMO and LUMO.⁴⁸ Ionization potential (IP) = $-E_{\text{HOMO}}$ corresponds to the electron donating ability of the inhibitor and characterizes the susceptibility of the molecule to donate electron. While the LUMO energy is related to the electron affinity (EA) = $-E_{\text{LUMO}}$ and portrays the tendency of the molecule to accept electrons. Efficient corrosion inhibitors are usually those organic compounds that can play the two roles; donating electrons to vacant orbital of the metal and acquiring free electrons from the metal surface. The lower the value of E_{LUMO} is, the higher the value of electron affinity, *i.e.*, the stronger the susceptibility of the molecule to accept electron. Thus, this reaction is also characterized with the transfer of electrons from the metal to the inhibitor and form a bond *via* back-donation from the metal surface to the π^* orbital of the inhibitor. This will strengthen the interaction between the inhibitor and the metal surface and accordingly increases its adsorption and inhibition efficiency.

Energy gap ($\Delta E = E_{\text{LUMO}} - E_{\text{HOMO}}$) is an important quantum parameter that can be used to understand the reactivity of the inhibitor molecule toward the adsorption on metallic surface. The lower the value of ΔE is, the more probable that the compound has inhibition efficiency. The results obtained from quantum chemical computations are summarized in Table 8. It is apparent from the computational results that LUMO energies decrease in the order of MA-0947 > MA-0941 > MA-0940, indicating that the ability of bichalcophene derivatives to accept electrons from CS surface following the order MA-0940 > MA-0941 > MA-0947. On the contrary, there was no link between the HOMO energies and the order of experimental η , this

finding is often explained by the complex nature of interactions in the adsorption process.⁴⁹ However, the ΔE was found to decrease in the order of MA-0947 > MA-0941 > MA-0940, which gives an indication that the stability of the formed complex on the metal surface follows the order of MA-0940 > MA-0941 > MA-0947 and this is due to the existence of S and N atoms in MA-0940 compound. Other quantum chemical parameters were used as reactivity descriptors in chemical reactions such as the absolute hardness, η , softness, σ , and electronegativity, χ . A soft molecule has lower energy gap while a hard one has higher energy gap. Hard molecule is less reactive than soft one because they could effectively donate electrons to a good electron acceptor. In inhibitive corrosion systems, the inhibitor works as a Lewis base while the metal behaves as a Lewis acid. Thus, the theoretical results indicated that MA-0940 would show the highest corrosion inhibition efficiency since it has the lowest ΔE and the highest softness value. Further, the order at which softness decreases along with the molecular reactivity was as follows: MA-0940 > MA-0941 > MA-0947; (σ).

Fig. 11 shows FMOs (HOMO and LUMO) and the electron density was found to be distributed evenly on the whole bichalcophene molecules, suggesting a parallel adsorption onto CS surface. Dipole moment is also another important structural index, but it is clear from the results that the values of dipole moment cannot be related (whether in consensus or in contrast) with the measured inhibition efficiency because the order at which dipole moment decreases, inhibition efficiency increases, by contrast, for the protonated form of inhibitors this order was changed in the reverse order, *i.e.*, the order at which dipole moment increased, inhibition efficiency increases. Accordingly, the experimental results is theoretically validated with ΔE and EA values as the order of these values calculated for neutral and protonated species is maintained and correlated with % η . We have also analyzed the HOMO, LUMO electronic

Table 8 Quantum chemical parameters calculated for bichalcophene inhibitors in aqueous solutions

Inhibitor	Total energy (au)	E_{HOMO} (eV)	E_{LUMO} (eV)	ΔE	η	σ (S)	χ	Dipole moment (debye)
Dmol³-neutral								
MA-0947	-839.05	-4.76	-2.81	1.950	0.98	1.03	3.79	2.61
MA-0941	-855.12	-4.90	-2.96	1.939	0.97	1.03	3.93	2.42
MA-0940	-1178.13	-4.96	-3.11	1.846	0.92	1.08	4.03	1.31
Dmol³-protonated								
MA-0947 ⁺	-839.51	-5.16	-3.34	1.820	0.91	1.10	4.25	12.59
MA-0941 ⁺	-856.01	-5.81	-4.01	1.800	0.90	1.11	4.91	17.08
MA-0940 ⁺	-1179.01	-5.85	-4.09	1.759	0.88	1.14	4.97	16.78
Gaussian DFT/RB3LYP/6-31(d,p)/neutral								
MA-0947	-838.77	-5.26	-1.60	3.66	1.83	0.55	3.43	4.21
MA-0941	-854.81	-5.38	-1.81	3.57	1.79	0.56	3.60	3.28
MA-0940	-1177.79	-5.44	-1.88	3.56	1.78	0.56	3.66	3.61
Gaussian DFT/RB3LYP/6-31(d,p)/protonated								
MA-0947 ⁺	-839.25	-5.48	-2.33	3.14	1.57	0.64	3.90	21.50
MA-0941 ⁺	-855.28	-5.59	-2.50	3.09	1.55	0.65	4.05	21.92
MA-0940 ⁺	-1178.26	-5.65	-2.52	3.13	1.56	0.64	4.09	23.60



distribution for the inhibitor molecules by Gaussian 09 and the results were in well accordance with the same using Dmol³ module in Material studio. Thereby after analyzing the electron density plots of HOMO and LUMO it is reasonable to say that the MA-0940 molecule acts as the best corrosion inhibitor among the three discussed molecules. The natural charges on atoms of studied compounds are presented in Fig. 12 where it is shown that nitrogen atoms (N19, N18) of amidino group bear more negative charge than other atoms, which indicates that these two atoms prefer to donate electrons to CS surface atoms and act as nucleophilic centers in interaction with the metal surface. Likewise, N4 in pyridine ring of (MA-0941, MA-0940)

has higher negative charge than C4, its comparable in position, in phenyl ring of (MA-0947), which means that N4 in pyridine ring is a strong structural feature that serves as an additional nucleophilic site and enhances the inhibition potential for (MA-0941 and MA-0940). Furthermore, positive charge (+0.452) is observed on S13 in thiophene ring of (MA-0940), this indicates that sulfur atom act as a strong electrophilic site which seems necessary for a good inhibitor to balance and counteract the negative charge accumulated on iron surface atoms *via* back-donation,⁵⁰ which is energetically favored as supported from the analysis of LUMO energy of MA-0940. The analysis of Fukui indices provide useful data about

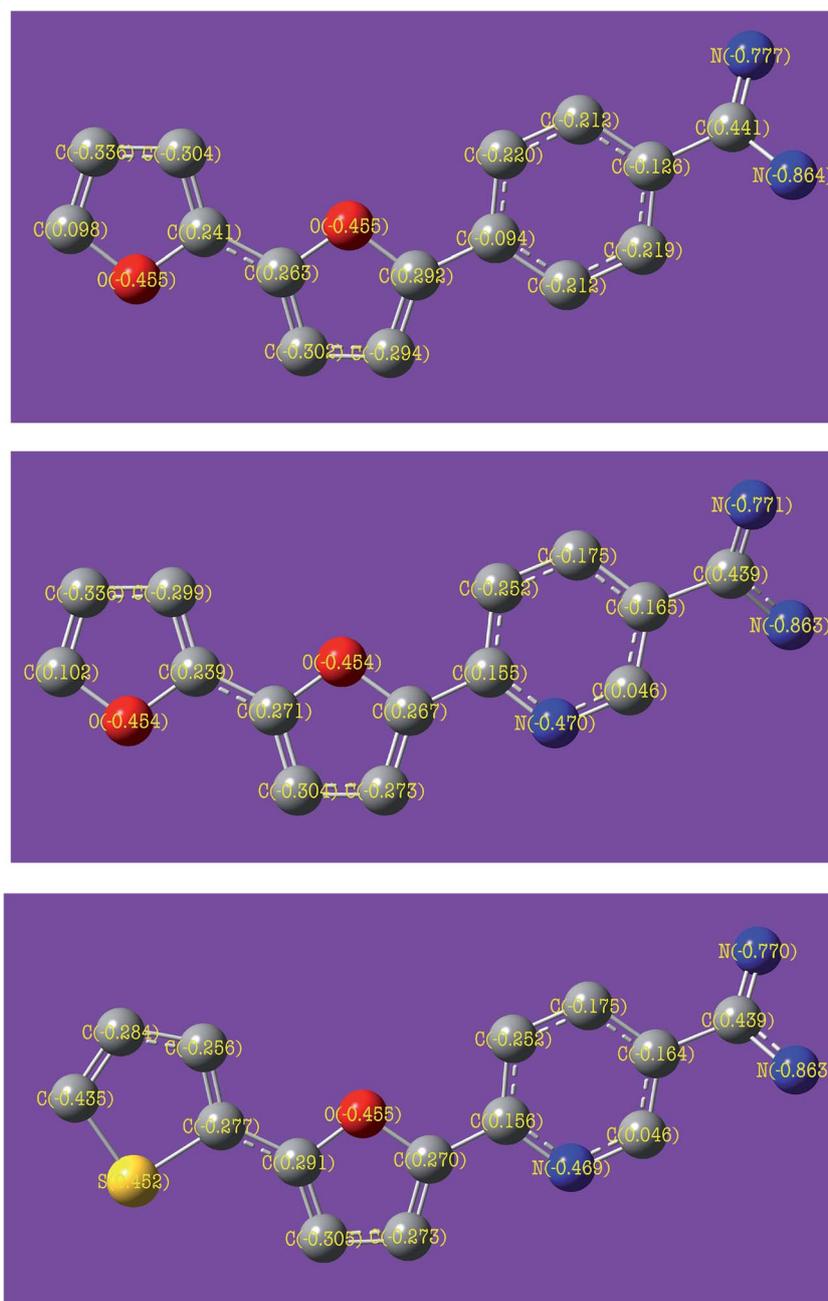


Fig. 12 Atomic charges (NBOs) calculated for investigated bichalcophene inhibitors calculated at DFT level and basis set 6-31 (d,p).



the local reactivity that atoms of organic compounds possess. By using the information obtained from Fukui functions, we can determine the atoms in a molecule with a higher tendency to accept and loose electrons. The nucleophilic (f^+) and electrophilic (f^-) Fukui indices were calculated using the finite difference approximation as follows.⁵¹

$$f^+ = q_{(N+1)} - q_N \quad (22)$$

$$f^- = q_N - q_{(N-1)} \quad (23)$$

where $q_{(N+1)}$, q and $q_{(N-1)}$ are the charges that atoms possess on systems with $N + 1$, N and $N - 1$ electrons respectively. The preferential centers for nucleophilic attack is the region/atom in the molecule where the value of f^+ is the highest while the site for electrophilic attack is the region/atom in the molecule where the value of f^- is the highest. The Fukui functions (f^+ , f^-) are given in Table 9 and graphically presented in the ESI (Fig. S7).[†] The results indicate that sulfur atom in MA-0940 contributes significantly in the nucleophilic and electrophilic attack which is in agreement with the HOMO analysis.

3.8. Monte Carlo simulation

Monte Carlo simulations was employed to identify the most stable adsorption sites on metal surfaces by identifying the lowest-energy adsorption configuration on both non-periodic and periodic substrates, besides investigating the preferential adsorption of mixtures of adsorbate components. The lowest energy configuration results from Monte Carlo simulation are presented in Fig. 13a. Several outputs and descriptors derived from Monte Carlo simulation are listed in Table 10.

Table 9 Fukui indices for the investigated bichalcophene derivatives calculated at DFT level using DMol⁵

MA-0947 ⁺			MA-0941 ⁺			MA-0940 ⁺		
Atom	fk^+	fk^-	Atom	fk^+	fk^-	Atom	fk^+	fk^-
C (1)	0.027	0.029	C (1)	0.013	0.052	C (1)	0.03	0.029
C (2)	0.019	0.019	C (2)	0.022	0.016	C (2)	0.019	0.019
C (3)	0.029	0.027	C (3)	0.04	0.038	C (3)	0.036	0.036
C (4)	0.029	0.031	N (4)	0.013	0.012	N (4)	0.01	0.011
C (5)	0.019	0.018	C (5)	0.028	0.027	C (5)	0.027	0.026
C (6)	0.031	0.030	C (6)	0.034	0.032	C (6)	0.030	0.031
C (7)	0.031	0.030	C (7)	0.033	0.030	C (7)	0.030	0.030
O (8)	0.022	0.018	O (8)	0.023	0.021	O (8)	0.019	0.020
C (9)	0.03	0.029	C (9)	0.032	0.029	C (9)	0.03	0.030
C (10)	0.032	0.034	C (10)	0.038	0.035	C (10)	0.031	0.031
C (11)	0.029	0.031	C (11)	0.034	0.033	C (11)	0.031	0.031
C (12)	0.030	0.028	C (12)	0.031	0.030	C (12)	0.014	0.018
O (13)	0.025	0.022	O (13)	0.026	0.026	S (13)	0.104	0.105
C (14)	0.042	0.043	C (14)	0.047	0.043	C (14)	0.033	0.033
C (15)	0.027	0.028	C (15)	0.032	0.030	C (15)	0.028	0.028
C (16)	0.033	0.035	C (16)	0.039	0.036	C (16)	0.033	0.033
C (17)	0.024	0.029	C (17)	0.031	0.022	C (17)	0.023	0.025
N (18)	0.021	0.020	N (18)	0.035	0.022	N (18)	0.025	0.027
N (19)	0.016	0.026	N (19)	0.029	0.027	N (19)	0.025	0.026

As can be inferred from the results in Table 10, the adsorption energies of the investigated molecules increased in the following order MA-0940 < MA-0941 < MA-0947, and MA-0940 shows the maximum negative adsorption energy. Therefore, MA-0940 provides the highest inhibition abilities as compared to the other two inhibitors. These findings confirmed the observations from quantum computational and the experimental results. The pair correlation function $g(r)$ was used to characterize the degree of atom disorder in the molecule and can give a measure of the probability of finding a pair of atoms at a given distance (r) in a random distribution. The pair correlation function has been applied in structural investigations of interaction between the liquid and solid materials and in studying specific interactions such as hydrogen bonding. The $g(r)$ of the super molecular system is obtained through analyzing the trajectory output of MD simulation.⁸ In this part, we will consider the distribution of heteroatoms (N, O, and S) according to their importance on the adsorption process of chemical compounds on the metal surface. The pair correlation function, $g(r)$, of C, N, S, and O of bichalcophene derivatives atoms and iron surface atoms was displayed in Fig. 13b. It is well recognized that the peak occurs at 1–3.5 Å, it's an indication of small bond length, which correlated to chemisorption, while the physical interactions (Coulomb and van der Waals forces) are associated with the peaks longer than 3.5 Å.⁵² For MA-0947-Fe (110) system, the highest peaks of RDF graphs for Fe–C4, Fe–N19, and Fe–N18 appear due to the formation of chemical bond at a distance 3.025, 3.025 and 4.075 Å respectively, while the existence of Coulomb forces between oxygen atoms and Fe surface atoms is indicated from the position of the highest peaks observed for Fe–O13 and Fe–O8 at 5.775 and 7.225 Å, respectively. Similar $g(r)$ curves obtained for MA-0941-Fe (110) system, the highest peaks of RDF curve of Fe–N4, Fe–N19, and Fe–N18 occur at a distance 2.775, 3.875 and 3.375 Å, while for Fe–O13 and Fe–O8 the highest peaks was noted at 8.175 and 5.225 Å, respectively. For MA-0940-Fe (110), the highest peaks of $g(r)$ curves for Fe–N4, Fe–N19, Fe–N18, Fe–O8 and Fe–S13 appear at a distance lower than 3.5 which composed of chemical bond.

3.9. Mechanism of corrosion inhibition

The studied bichalcophenes exhibited good inhibition efficiencies which follow the order MA-0940 > MA-0941 > MA-0947 (Fig. 14). Their corrosion inhibition potentials account for some molecular structure features and the presence of heteroatoms; sulfur in thiophene and nitrogen in pyridine ring which serve as strong adsorption centers and enhance its inhibition efficiency. CS surface is accumulated with negative charge when immersed into HCl media because chloride ions adsorb on the metal surface $[\text{Fe} + \text{Cl}^{-1} \cdots (\text{FeCl}^{-})_{\text{ads}}]$. In acid solutions bichalcophene derivatives could be easily protonated, $[\text{MA-0940}], 1, 7] + \text{H}^+ \rightleftharpoons [\text{MA-0940}], 1, 7]^+$, due to high electron density on it, leading to positively charged inhibitor species. The physical adsorption could occur *via* electrostatic interaction between protonated inhibitor molecules (+ve) and negatively charged CS surface (–ve).⁵³ Additionally, chemical adsorption could occur *via*



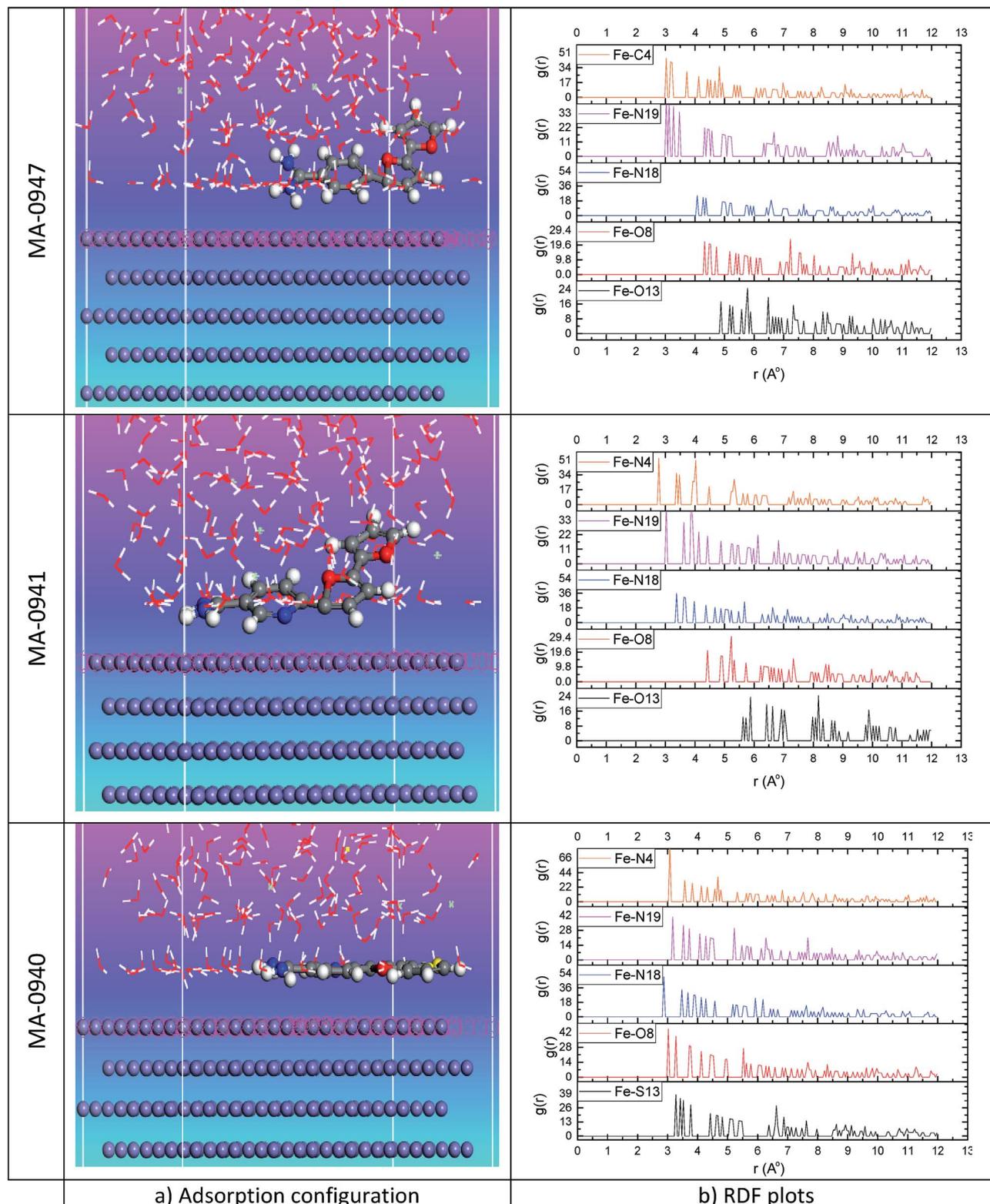


Fig. 13 (a) Equilibrium configuration adsorption of investigated bichalcophene on Fe (110) surface in HCl solution (b) RDF of C, N, O and S atoms from investigated compounds and Fe atoms from Fe (110).

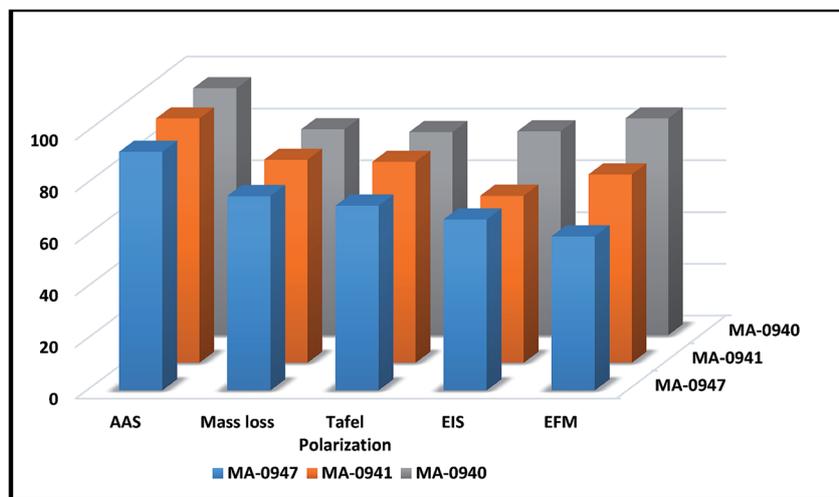
interaction of π -electrons of the aromatic rings of inhibitor with vacant d-orbitals of CS, results in formation of coordinate type of bond.⁵⁴ Coordination bond can also be formed between the

unshared electrons on hetero atoms and vacant d-orbitals of Fe atoms on CS surface. MA-0940 was the most efficient one because it has the highest molecular weight (342.2) and



Table 10 Data from MD modelling for adsorption of bichalcophene derivatives on Fe (110). The interaction energies (kcal mol⁻¹)

System	Total energy (kcal mol ⁻¹)	Adsorption energy (kcal mol ⁻¹)	Rigid adsorption energy (kcal mol ⁻¹)	Deformation energy (kcal mol ⁻¹)	Compound dE _{ad} /dN _i
MA-0947	-3295.51	-3703.20	-3536.73	-166.46	-232.94
MA-0941	-3298.93	-3695.25	-3521.69	-173.56	-241.94
MA-0940	-3292.66	-3710.95	-3505.69	-205.26	-253.79

**Fig. 14** Comparison of % η obtained from experimental techniques for corrosion of CS in 1 M HCl solutions containing 18×10^{-6} M of investigated compounds at 25 °C.

contains 3N, O, and S atom which is less electronegative and more basic than N and O atoms, so it shares more electrons to the molecule than N and O atoms. Compound MA-0941 comes after MA-0940 in % η because the molecular size (336.3) is lower and it contains 3N and 2O atoms only. Compound MA-0947 is the least effective one due to, it has the least molecular size (288.7) and it has only 2N and 2O atoms.

inhibition efficiency, for the investigated bichalcophenes, is as follows: MA-0940 > MA-0941 > MA-0947.

Conflicts of interest

There are no conflicts to declare.

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4. Conclusions

From the outcome of our investigation, it is possible to conclude that:

The corrosion inhibition efficiency of investigated bichalcophene compounds from ML, PP, EIS and EFM methods are in good agreement. PP studies revealed that bichalcophene derivatives act as mixed-type inhibitors. EIS measurements were analyzed to model the corrosion inhibition process by testing the appropriate equivalent circuit, a constant phase element (CPE) has been used. These bichalcophene compounds chemisorbed on metal surface and their adsorptions correspond to Langmuir's adsorption model with a large negative value of the free energy of adsorption $\Delta G_{\text{ads}}^{\circ}$. Surface examination *via* means of AFM shows a remarkable mitigation of CS corrosion by formation of protective layer on CS surface. Both quantum chemical calculation and molecular dynamic simulations supported the experimental results that showed MA-0940 and MA-0941 as efficient corrosion inhibitors, and the order of



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